AMENDMENTS TO THE CLAIMS

(Currently amended) A copolymer containing 70 to 99% by weight based on the copolymer of polyoxymethylene blocks of the structural repeat units of the formula I and from 1 to 30% by weight, blocks containing structural units of the formula II

$$[-O-CH_2-]_x$$
 (I), $[-O-R^1-]$ (II),

where R^1 is a divalent radical derived from a hydroxy-terminated aliphatic or cycloaliphatic oligomer or polymer which optionally has ether groups and/or carbonyloxy groups in the chain, and x is a whole number, at least 10.

- 2. (Previously presented) The copolymer as claimed in claim 1, wherein x is a whole number from 500 to 10,000.
- (Previously presented) The copolymer as claimed in claim 1, wherein said
 polyoxymethylene blocks also contain structural repeat units of the formula III

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$$(C_yH_{2y}$$
-O- $)_z$ (III),

besides the structural repeat units of the formula I, where y is a whole number from 2 to 4, and z is a whole number from 1 to 3.

- 4. (Previously presented) The copolymer as claimed in claim 1, wherein R^1 is a $-(C_mH_{2m}-O_r-C_mH_{2m}-radical)$ radical, m is a whole number from 2 to 4, and r is a whole number from 20 to 1,500.
- 5. (Original) The copolymer as claimed in claim 4, wherein m is 2.

6. (Previously presented) A process for preparing the copolymer as claimed in claim 1, encompassing the following measures:

(i) forming an initial charge from monomers which form -O-CH₂- units together with monomers of the formula V

$$HO-R^1-OH$$
 (V),

where R^1 is as defined in claim 1, together with a catalyst usually used for polymerizing the monomers forming the -O-CH₂- units, and optionally together with a solvent, and/or with regulators, and

- (ii) carrying out the copolymerization at a temperature of from 120 to 300°C and at a pressure of from 2 to 500 bar.
- 7. (Previously presented) The process as claimed in claim 6, wherein the resultant block copolymer is treated, after the preparation, with water and/or with a water-soluble alcohol at from 30 to 100°C.
- 8. (Cancelled)
- 9. (Previously presented) The copolymer as claimed in claim 1, wherein x is a whole number from 1,500 to 5,000.
- 10. (Previously presented) The copolymer as claimed in claim 1, wherein R^1 is a $-(C_mH_{2m}-O_r-C_mH_{2m}-C_mH_$

11. (Previously presented) The process as claimed in claim 6, wherein the resultant block copolymer is treated, after the preparation, with water and/or with a water-soluble alcohol at from 50 to 80°C.

- 12. (Previously presented) A molding comprising the copolymer as claimed in claim 1.
- 13. (New) The copolymer as claimed in claim 1, wherein said blocks composed of homo- or copolyoxymethylenes in the copolymer of the formula I is from 80 to 95% by weight, and the proportion of structural repeat units of the formula II is from 5 to 20% by weight, based on the copolymer.
- 14. (New) The copolymer as claimed in claim 1, wherein said polyoxymethylene blocks are prepared by reacting trioxane with a cyclic ether and with a third monomer of the formula

$$R^2$$
-- CH_2 - Z - CH_2 -- R^2 -,

where R² and R², independently of one another, are radicals of the formula IVa, IVb, or IVc

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wherein Z is a chemical bond, --O--, or --O--R³--O---and

R³ is C₂-C₈-alkylene or C₂-C₈-cycloalkylene.

- 15. (New) The copolymer as claimed in claim 1, which further contains from 0.1 to 20 mol %, based on the copolymer block, of co-components which are derived from ethylene oxide, propylene 1,2-oxide, butylene 1,2-oxide, butylene 1,3-oxide, 1,3-dioxane, 1,3-dioxane, and 1,3-dioxepan.
- 16. (New) The copolymer as claimed in claim 1, which further contains from 0.5 to 10 mol %, based on the copolymer block, of co-components which are derived from ethylene oxide, propylene 1,2-oxide, butylene 1,2-oxide, butylene 1,3-oxide, 1,3-dioxane, 1,3-dioxane, and 1,3-dioxepan.
- 17. (New) The copolymer as claimed in claim 1, wherein the formula I is present in an amount from at least 80% by weight.
- 18. (New) The copolymer as claimed in claim 1, wherein the formula I is present in an amount from at least 90% by weight.